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CONFIRMATION NO. 5294

Bib Data Sheet

SERIAL NUMBER 10/716,142	FILING DATE 11/19/2003  RULE	CLASS 438	GROUP ART UNIT 2812	ATTORNEY DOCKET NO. 245583US0S DIV
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## APPLICANTS

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## \*\* CONTINUING DATA \*\*\*\*\*

This application is a DIV of 10/241,488 09/12/2002 PAT 6,677,660

## \*\* FOREIGN APPLICATIONS \*\*\*\*\*

JAPAN 2002-235073 08/12/2002

## IF REQUIRED, FOREIGN FILING LICENSE GRANTED

\*\* 02/18/2004

Foreign Priority claimed

☒ yes ☐ no

35 USC 119 (a-d) conditions met

☒ yes ☐ no ☐ Met after Allowance

Verified and Acknowledged

Examiner's Signature

Initials

STATE OR

COUNTRY  
JAPAN

SHEETS

DRAWING  
27

TOTAL

CLAIMS  
7

INDEPENDENT

CLAIMS  
2

## ADDRESS

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ALEXANDRIA, VA

22314

TITLE METHOD OF MANUFACTURING ASemiconductor device having silicide film and manufacturing method thereof

FILING FEE	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:	<input type="checkbox"/> All Fees
RECEIVED 770		<input type="checkbox"/> 1.16 Fees ( Filing ) <input type="checkbox"/> 1.17 Fees ( Processing Ext. of time ) <input type="checkbox"/> 1.18 Fees ( Issue ) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit